

INC3 Speaker's Biography

Hajime Sasaki, NEC Corporation



Mr. Hajime Sasaki entered NEC in April 1961 after obtaining a master's degree in electrical engineering from the University of Tokyo. He immediately started designing integrated circuits for communications applications. His senior management career began in 1982 when he became the general manager of the VLSI Development Division. After other executive positions including vice president, associate senior vice president, senior vice president, executive vice president, and senior executive vice president, he was promoted to chairman of the board in 1999 and continues to carry out that role.

Mr. Sasaki has been an active part of numerous Japanese industry organizations. These include serving as the chairman of the Communications Industry Association of Japan (CIAJ) from 1999 to 2000, the chairman of the Japan Electronics and Information Technology Industries Association (JEITA) from 2003 to 2004, and the chairman of the Committee on Global Environment and Energy Policy at the Japan Association of Corporate Executives (KEIZAI DOYUKAI) from 2003 to 2006. He has also been the co-chairman of the Committee on Europe at the Japan Business Federation (Nippon Keidanren) since 2000, the chairman of the Japanese Standards Association since 2001, and the president of the Japan Federation of Engineering Societies since 2003. And in 2005, he was appointed chairman of the Nanotechnology Business Creation Initiative.

Mr. Sasaki has been given various awards and honors over his career. He received the "Award of Persons of Scientific and Technological Merits" from the Science and Technology Agency of the government of Japan in 1995. In 2000, he became a Foreign Associate of the National Academy of Engineering (NAE) and received the Third Millennium Medal from the IEEE. In 2001, he was awarded the Robert N. Noyce Medal from the IEEE "for contributions to, and leadership in, the technology and business development of semiconductor devices and the harmonization of the global semiconductor industry" and became a Life Fellow of the IEEE. In addition, he received the Deming Prize for Individuals in 2005, The Legion d'honneur (Legion of Honor) in 2006, and The Sheffield Fellowship from Yale University the same year.